

















Решение обр	атной задачи		$\overline{\mathbf{X}}$
b, mm	R0, Om	Pars	
20		90 20 800 500 135	h1, mm h2, mm ro1, 0msm ro2, 0msm ro3, 0m <b>\$pecific resistance of second layer</b> vs. time
а, mm Расчет	100 Закрыть	Прас	Фик.
Во	rders of first a	nd secon	nd layers are dynamically changed

ecision of model parameter's determination in case of solution of indirec k by using apparent resistivity conception.											
N	ρ <sub>lgen,</sub> Ohm·cm	h <sub>1gen,</sub> cm	ρ <sub>2gen,</sub> Ohm·cm	ρ <sub>1cale,</sub> Ohm∙cm	h <sub>leale,</sub> cm	ρ <sub>2eale,</sub> Ohm∙cm	δρ <sub>1,</sub> %	δh <sub>1,</sub> %	δρ <u>2</u> , %		
1	750	5	120	749	4.9	131	< 0.5	2.0	9		
2	820	7	110	819	6.8	134	< 0.5	3.0	22		
3	760	11	130	760	10.7	160	< 0.5	2.7	23		
4	750	9	140	750	8.9	150	< 0.5	1.1	7		
5	770	10	150	770	9.9	159	< 0.5	1.0	6		

























